

## Freeform Search

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<b>Database:</b>	US Pre-Grant Publication Full-Text Database US Patents Full-Text Database US OCR Full-Text Database EPO Abstracts Database JPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins
<b>Term:</b>	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (resolve adj differences adj between adj
<b>Display:</b>	<input style="width: 50px;" type="text" value="50"/> <b>Documents in Display Format:</b> <input style="width: 50px;" type="text" value="-"/> <b>Starting with Number</b> <input style="width: 50px;" type="text" value="1"/>
<b>Generate:</b> <input type="radio"/> Hit List <input checked="" type="radio"/> Hit Count <input type="radio"/> Side by Side <input type="radio"/> Image	

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Search

Clear

Interrupt

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### Search History

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**DATE:** Tuesday, January 25, 2005   [Printable Copy](#)   [Create Case](#)

<u>Set</u> <u>Name</u> <small>side by side</small>	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> <small>result set</small>
	<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=NO; OP=OR</i>		
<u>L19</u>	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (resolve adj differences adj between adj measurements)	2	<u>L19</u>
<u>L18</u>	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (first adj parameter) and (second adj parameter)	2	<u>L18</u>
<u>L17</u>	5871805.pn.	2	<u>L17</u>
<u>L16</u>	(deposit\$3 adj chamber) and (configur\$3) and (wafers) and (measur\$3 adj3 thickness adj3 wafer) and (pattern)	8	<u>L16</u>
<u>L15</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers)	29	<u>L15</u>
<u>L14</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (pattern adj5 thickness)	0	<u>L14</u>
<u>L13</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 thickness)	0	<u>L13</u>
<u>L12</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 thickness) and (pattern)	0	<u>L12</u>
<u>L11</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 tickness) and (pattern)	0	<u>L11</u>
<u>L10</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (measur\$3 adj tickness) and (pattern)	0	<u>L10</u>
	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and		

<u>L9</u>	(measur\$3 adj tickness) and (deposition adj pattern)	0	<u>L9</u>
<u>L8</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (measur\$3 adj thickness) and (pattern)	28	<u>L8</u>
<u>L7</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (thickness) and (pattern)	29	<u>L7</u>
<u>L6</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (thickness) and (pattern)	29	<u>L6</u>
<u>L5</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (thickness) and (pattern)	0	<u>L5</u>
<u>L4</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj thickness) and (pattern)	0	<u>L4</u>
<u>L3</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj thickness) and (deposition adj pattern)	0	<u>L3</u>
<u>L2</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj tickness)	0	<u>L2</u>
<u>L1</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj tickness) and (deposition adj pattern)	0	<u>L1</u>

END OF SEARCH HISTORY